

# Detectors for Wide Field Imaging

Gavin Dalton

With input from Paul Jorden, Peter Poole, Peter Dennis, David Hall, David Lees, John Cairns, Keith Barnes, Ian Baker, Les Hipwood, Gert Finger, Jim Beletic

# Overview

- Current status of CCDs
- Current IR detectors
- Developments in IR detectors
- Prospects

# CCDs

☞ Fairchild

☞ LBNL (Hamamatsu)

☞ e2V

# CCDs

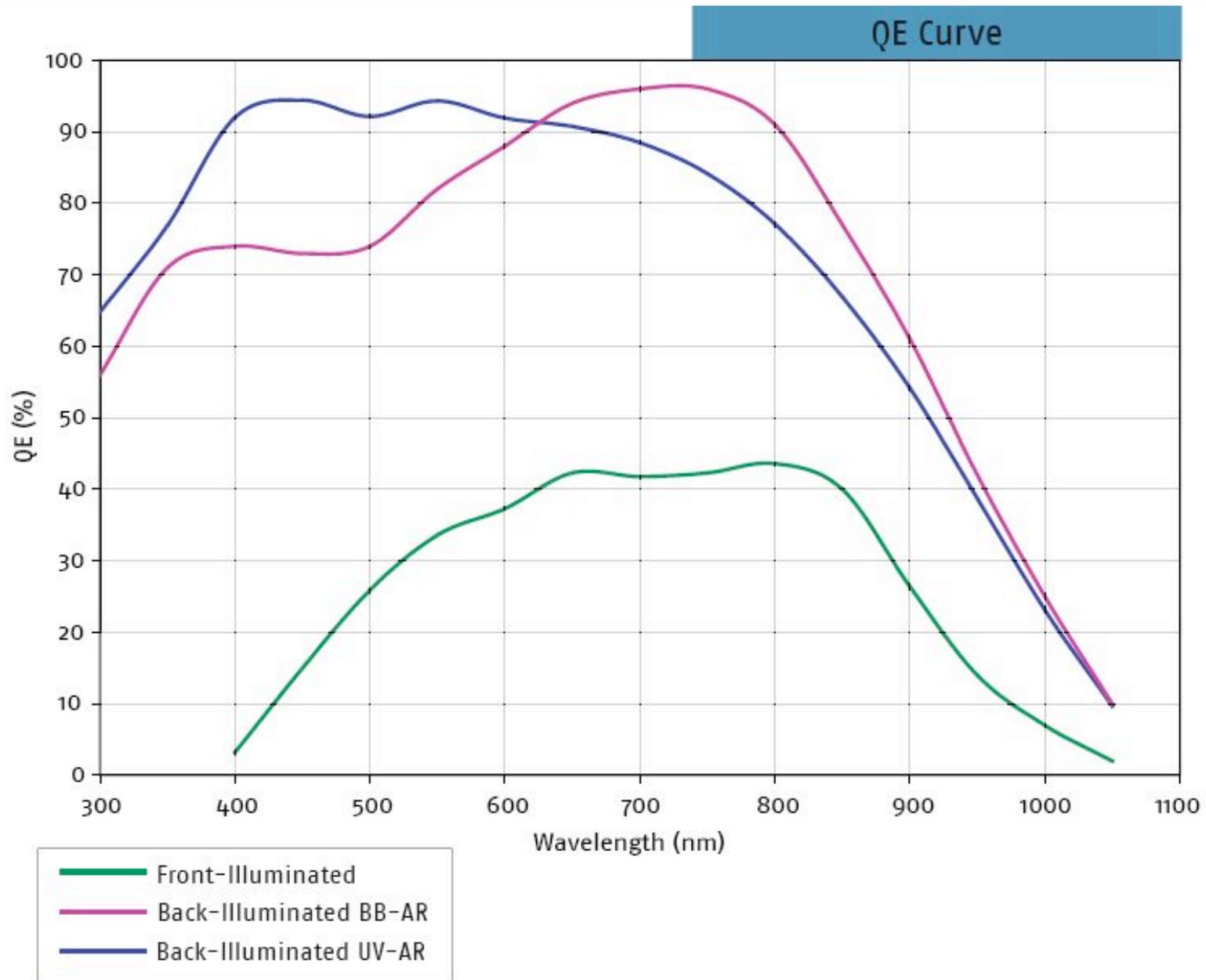
🐣 Fairchild

CCD486, 4kx4kx15 $\mu$ m

Better q.e. and slightly lower dark current than e2V CCD231 due to multi-phase pinning, but also higher readout noise

In recent discussions, Fairchild appeared to have no interest in developing larger format CCDs

# Fairchild q.e. curve



# CCDs

🐛 LBNL Hi-rho

Extremely red sensitive chips developed at LBNL, now also available from Hamamatsu(S10892-01) or e2V

Requires high voltage (100V) bias board, but can be incorporated into a standard controller

Some devices have been found to be extremely sensitive to ESD damage

# CCDs

☞ e2V

Stable production process based on building blocks

Blue, Red and High-rho devices available

Anti-fringing options (variable pixel heights)

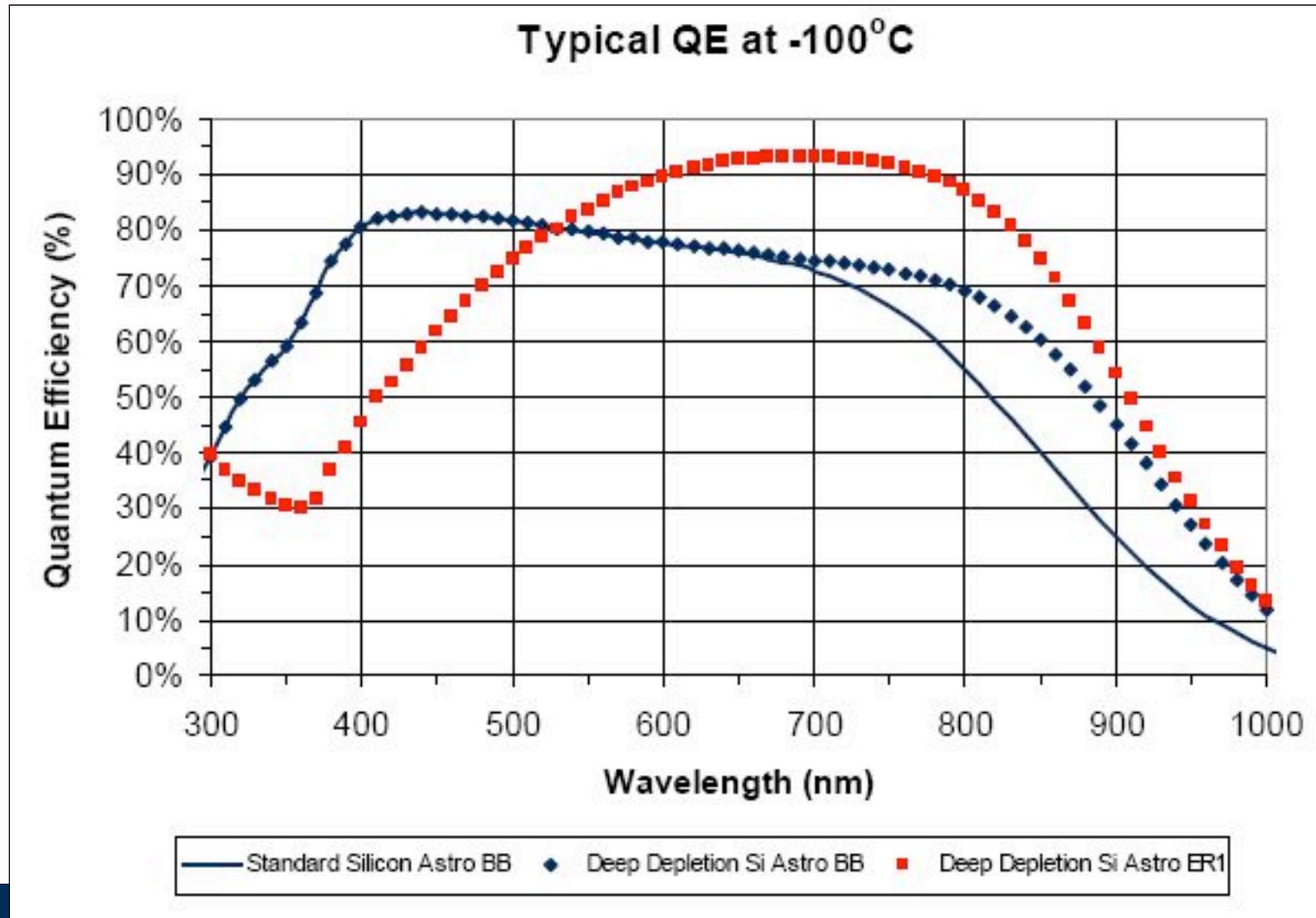
Provides a simplified controller interface

Avalanche gain, not yet mapped to larger formats

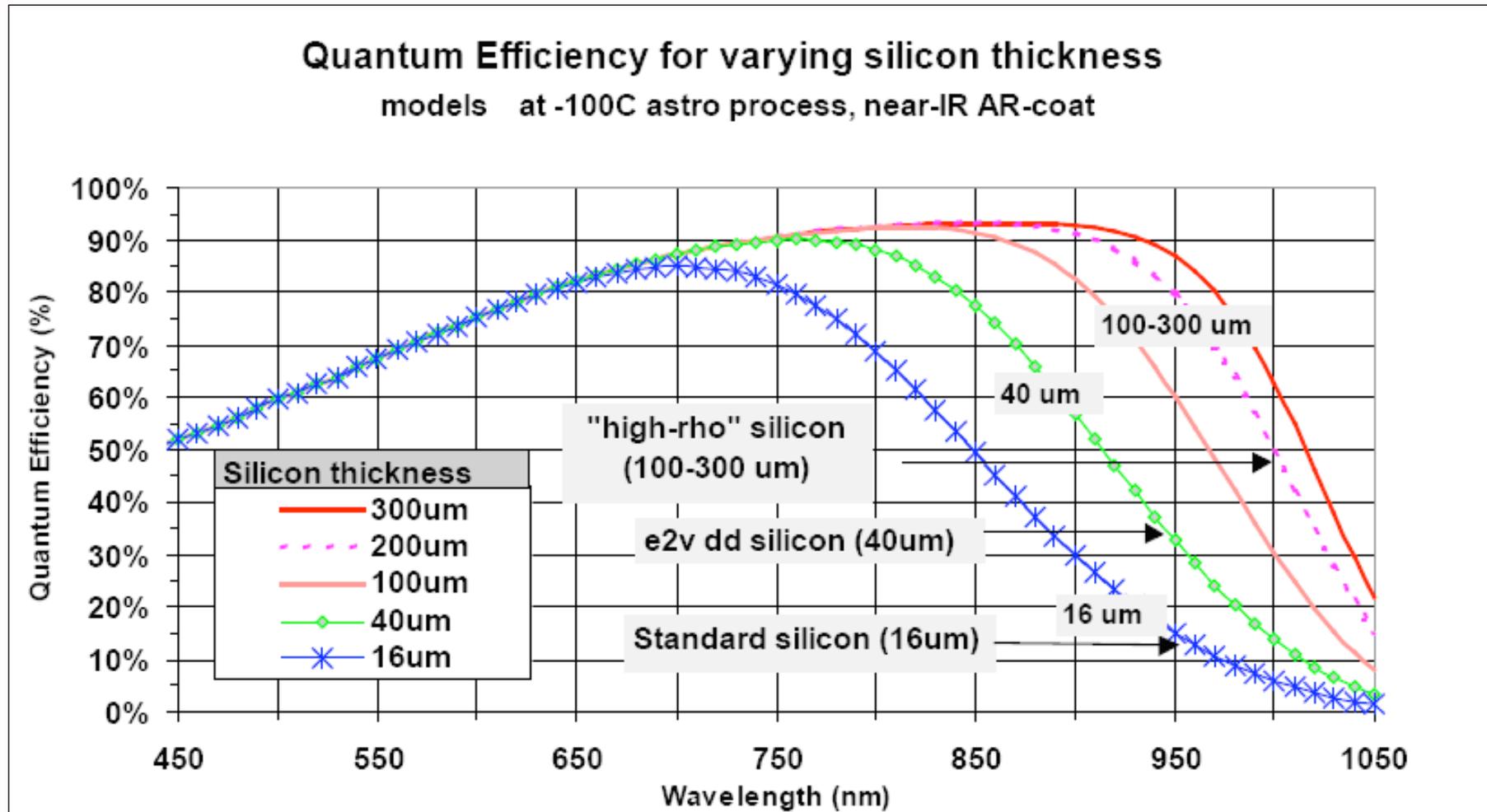
Formats up to 8kx3k have been manufactured (larger than 4kx4k is probably lower cost for large systems)

Also making 10 $\mu$ m pixel high-rho devices for LSST

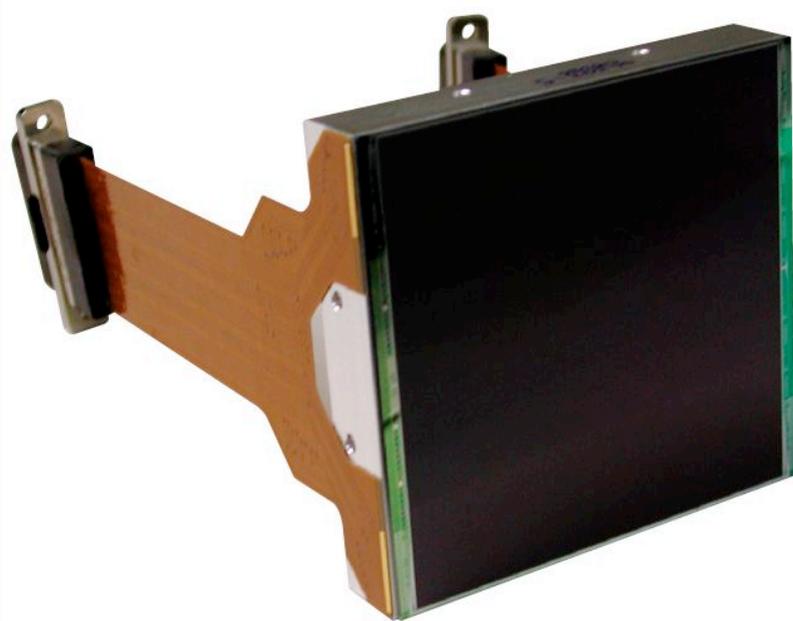
# e2V q.e. curves



# e2V q.e. curves



# e2V package



15 $\mu$ m pixels

2e<sup>-</sup> noise at 50kHz readout

5e<sup>-</sup> noise at 1MHz readout

SiC package provides 20 $\mu$ m flatness

CCD231-84 package

# Current IR arrays

## ☞ Raytheon

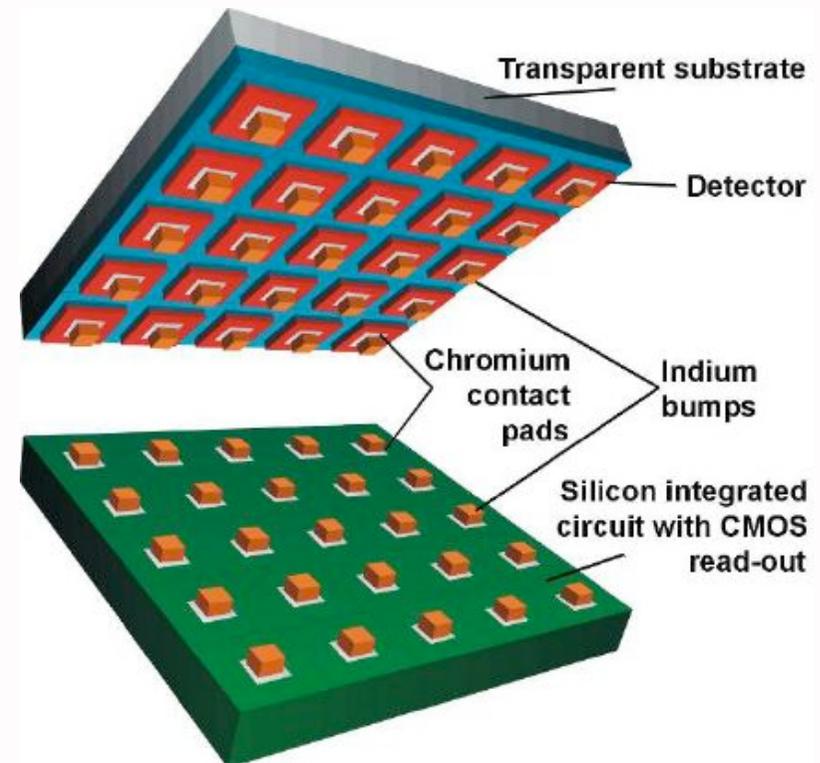
- 2kx2kx20 $\mu$ m VIRGO chips (VISTA)
- 2.5 $\mu$ m cut-off, good q.e, poor cosmetics
  - Low cost option, mixed experience from VISTA
  - 3-edge-butable

## ☞ Teledyne

- 2kx2kx18 $\mu$ m HAWAII-2RG
- 2.5 or 1.7 $\mu$ m cut-off, substrate removed
- 3-edge buttable
- Highly functional ROIC with option for multiple fast readout windows to prevent saturation and persistence
- SIDECAR integrated ASIC controller

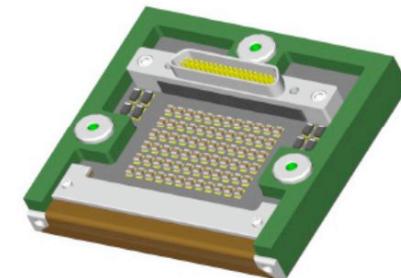
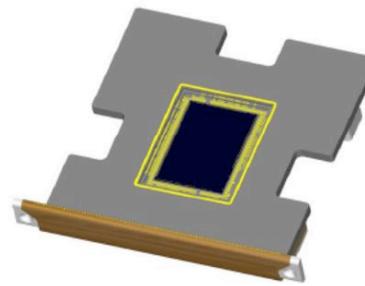
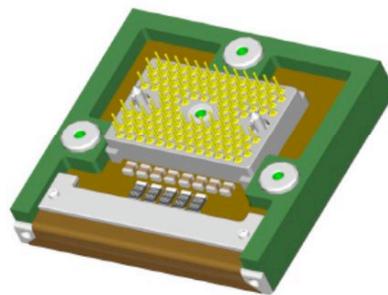
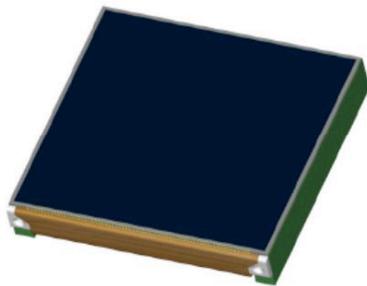
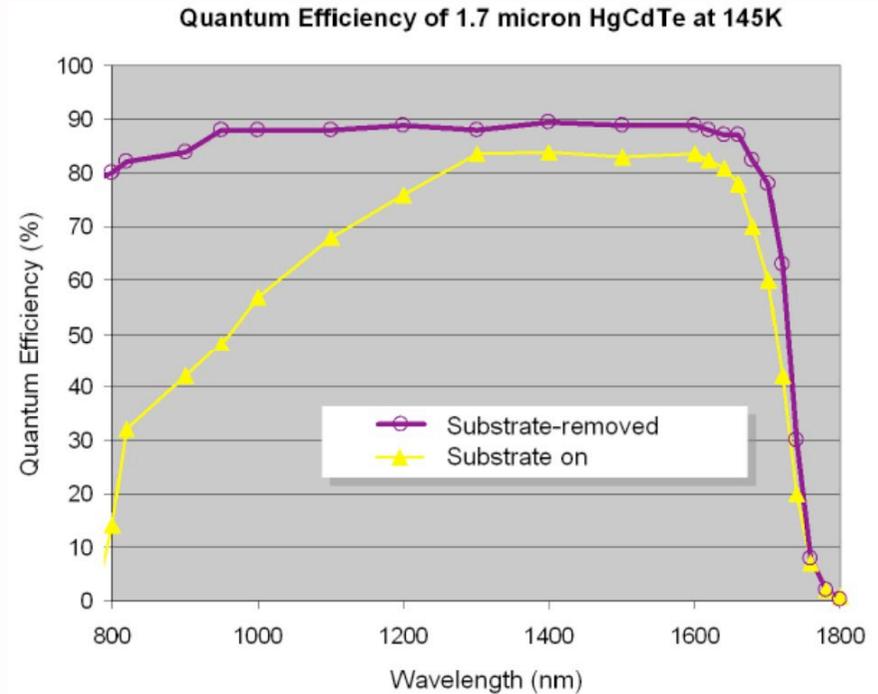
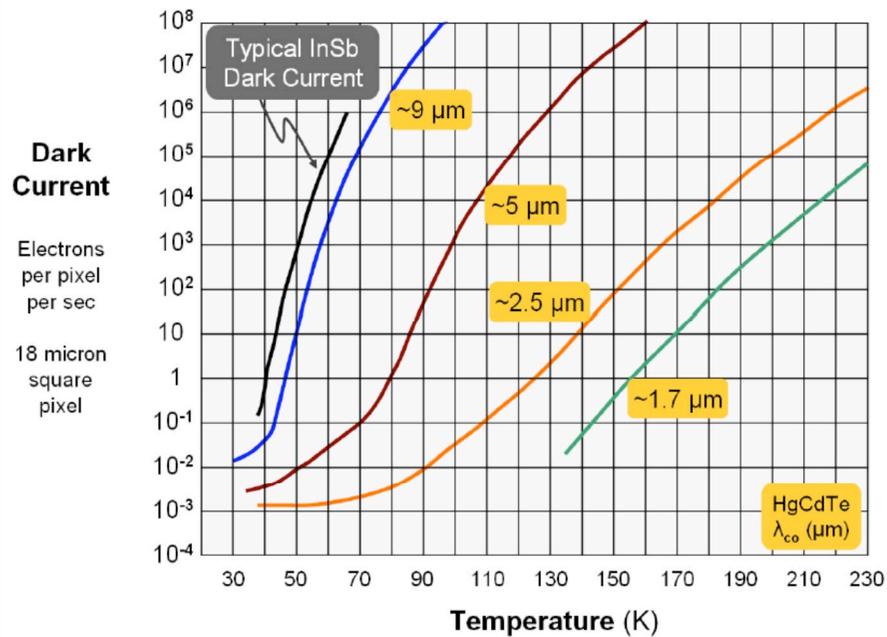
# Array Fabrication Technology

- ☞ HgCdTe layer grown on ZnCdTe substrates (good lattice match) using MBE (RVS still using LPE)
- ☞ Detector layer hybridised to Si CMOS ROIC
- ☞ Limitations on array size, performance and yield/lifetime (-> cost)



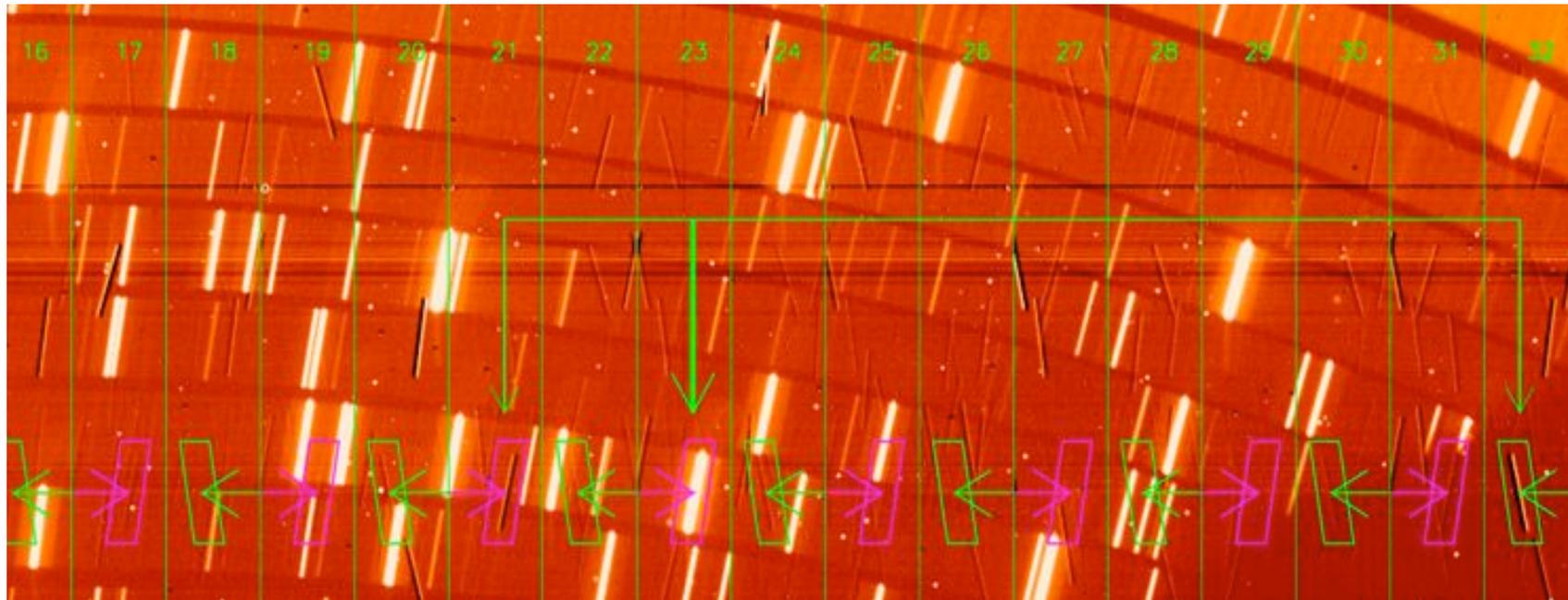
# Teledyne developments

Developing 2kx2kx30 $\mu$ m array  
as precursor to 4kx4kx15 $\mu$ m  
HAWAII-4RG



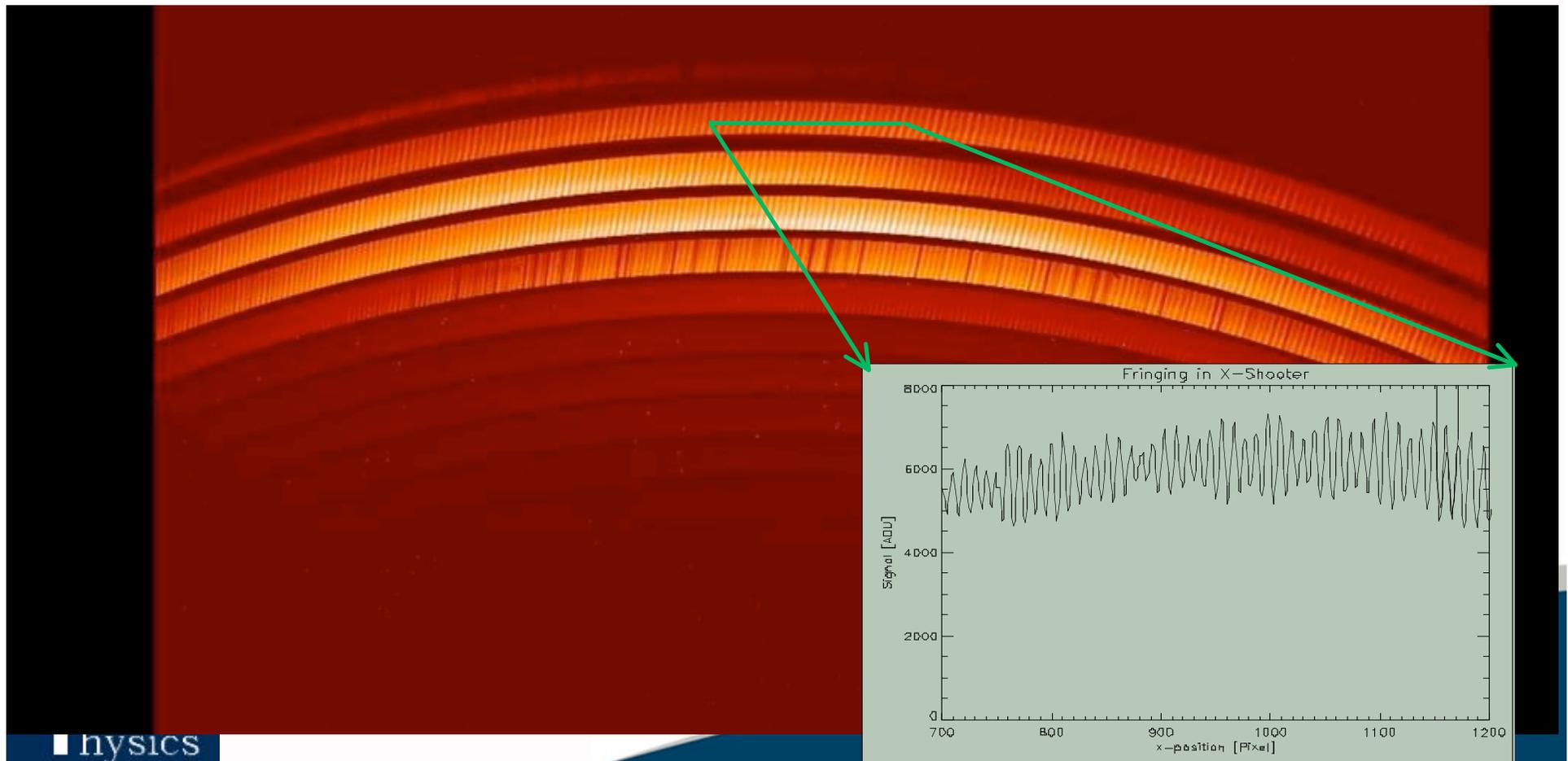
# Performance Issues

- ☛ Channel cross-talk (from ESO's X-Shooter, courtesy G. Finger)



# Performance Issues

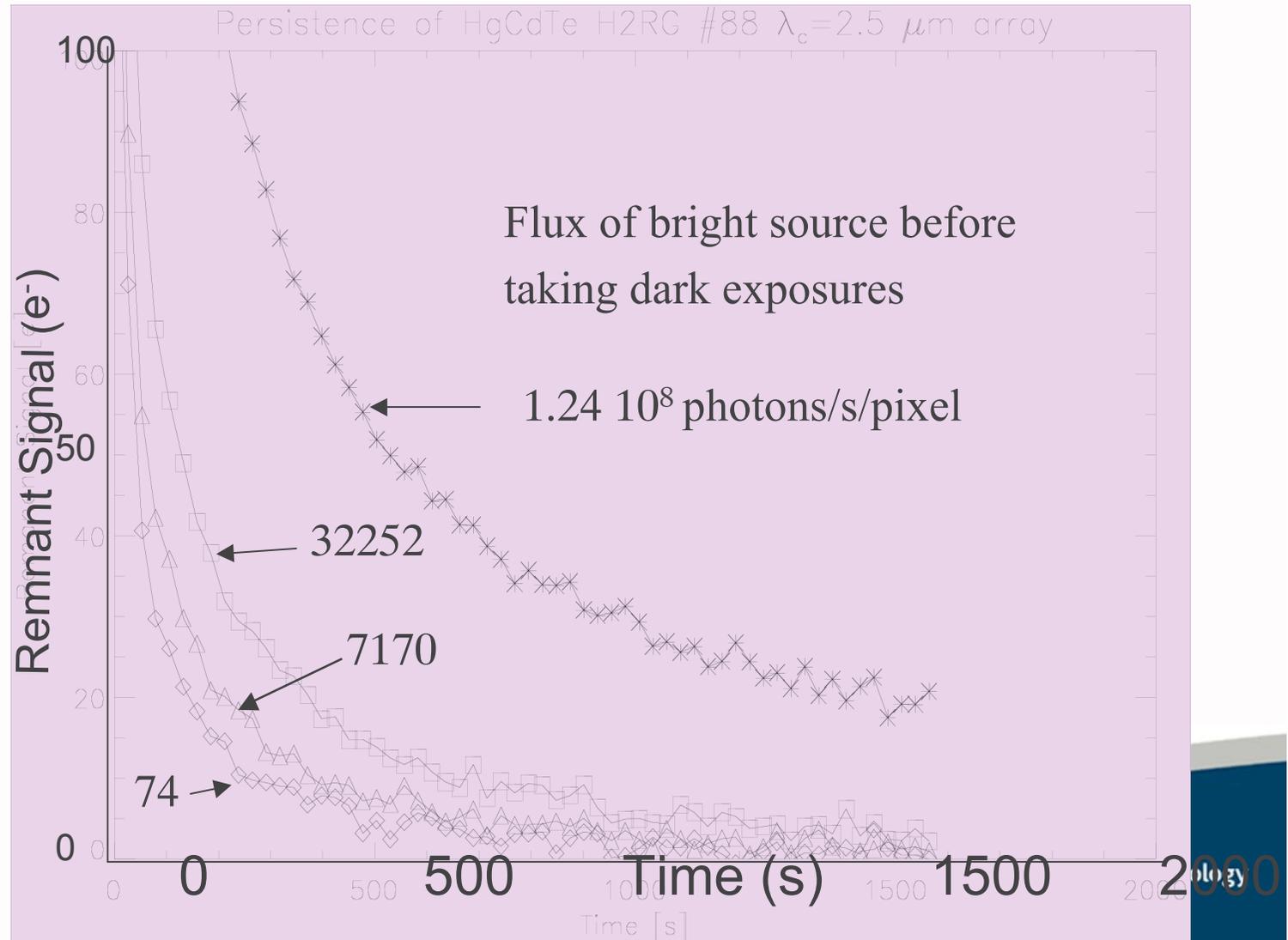
Fringing due to substrate...



# Performance Issues

## ☞ Persistence...

Remnant image of bright source in preceding exposure sometimes visible for hours after event.



# Performance Issues

## ☞ Inter-pixel capacitance

- Leads to over-estimation of system gain, and hence quantum efficiency

## ☞ Photo-emission defects

- Occasionally individual pixels seen to act as bright IR LEDs

## ☞ Catastrophic failures...

- A large number of early arrays have now been observed to delaminate after repeated cold cycling

# New developments in IR

## ☞ ESA TRP for Cosmic Visions

- Promote development of EU competitor to Teledyne for next generation space missions

## ☞ SELEX-Galileo

## ☞ QinetiQ

# Evolution of 2D arrays at SELEX

by Merlin MWIR

**OSPREY 384 x 288**

24 $\mu$ m pitch MW and LW

**EAGLE 640 x 512**

24 $\mu$ m pitch MW and LW

**HAWK 640 X 512**

16 $\mu$ m pitch MW and LW

Dry etched mesas

**MERLIN 1024 x 768**

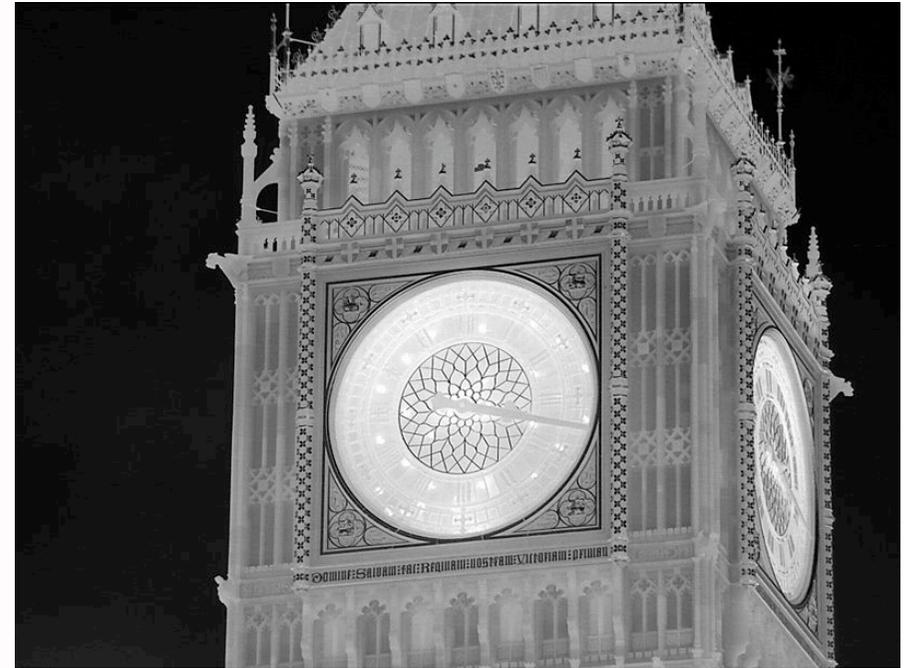
16 $\mu$ m pitch MW and LW

Dry etched mesas

**CONDOR 640 x 512**

24 $\mu$ m pitch Two Colour

Dry etched mesas



Larger area

Smaller pixels

Multicolour detectors



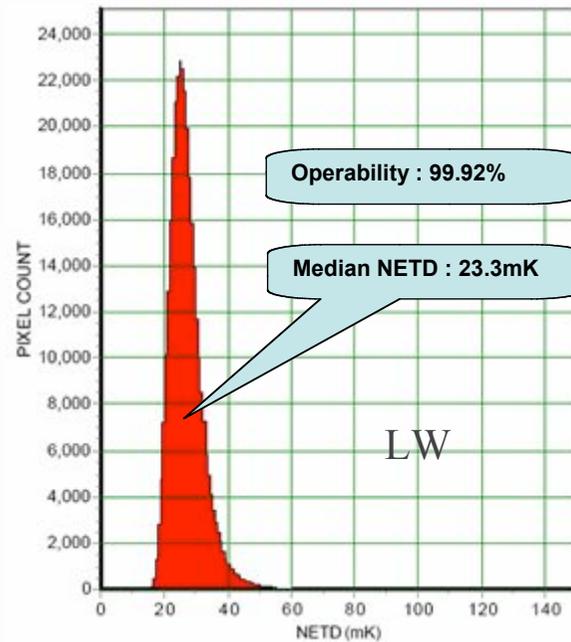
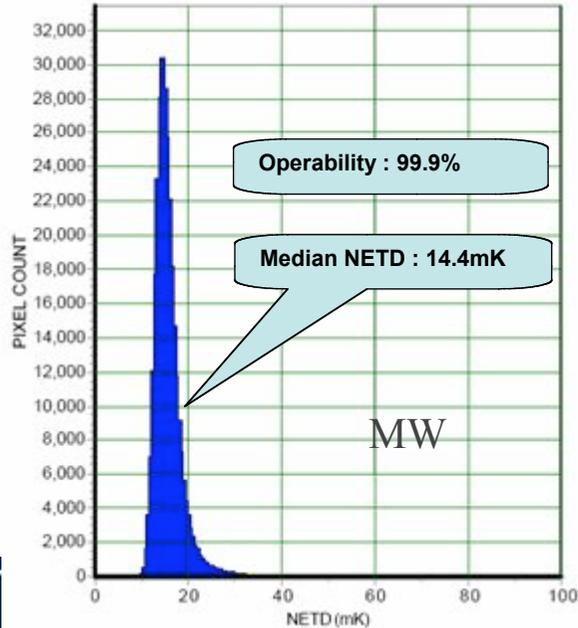
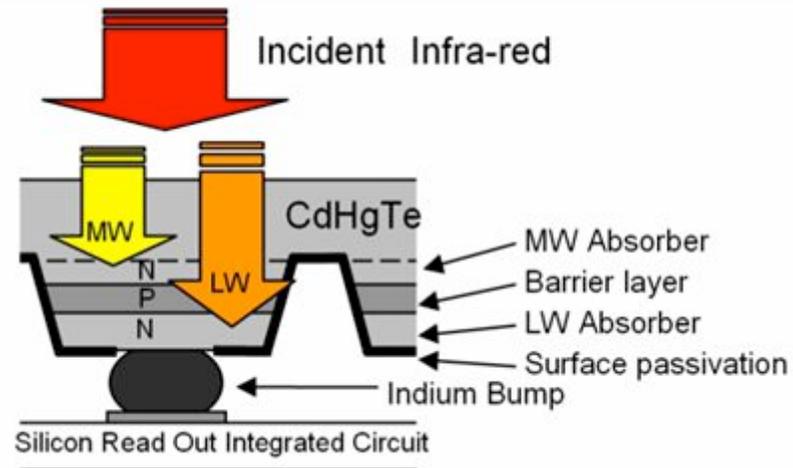
# SELEX Capabilities

- HgCdTe grown by MOVPE on GaAs substrates then hybridised
- GaAs 100x less expensive than lattice matched CdZnTe
- Multiple suppliers (CZT has limited no. of commercial suppliers)
- Wafer scale (150mm) processing using standard semiconductor equipment
- Few mask stages
- New bump bonder being installed. 150mm array end-end capability
- Should be able to produce low-cost equivalent of HAWAII-2RG devices

# Two-Colour Detectors

☞ N-P-N diode structure

- Spatially coincident MW/LW pixels



# Evolution of 2D arrays at QinetiQ

**HgCdTe as IR detector invented at Malvern in 1959**



**128 x 128 HgCdTe hybridised on Si  
55µm pitch LW (10µm)  
1024 x 768 HgCdTe hybridised on Si  
26µm pitch LW (9.6µm)**

**Dual band arrays  
30µm pitch MW and LW  
two capacitors/pixel**

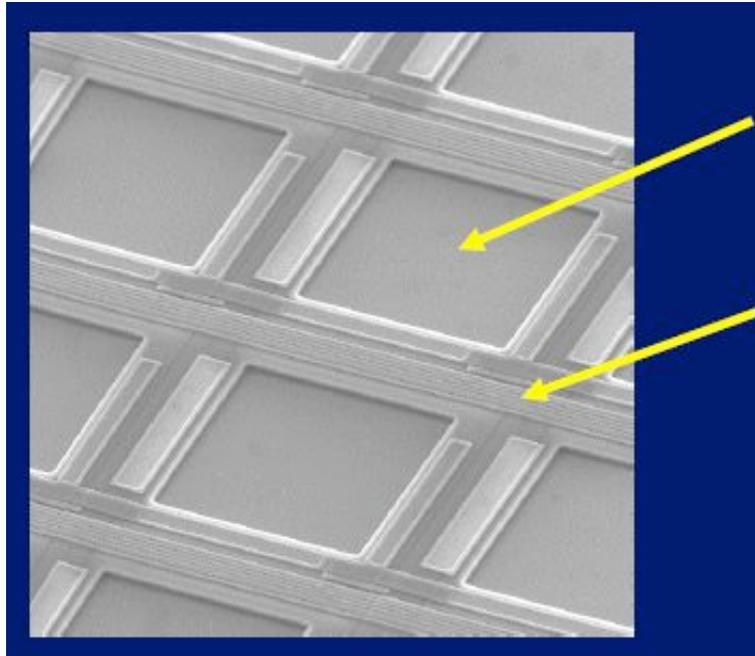


# Developments - QinetiQ

- MOVPE growth at high T gives much more control of growth environment than MBE process
- Direct growth onto ROIC mesas - no substrate
- Si substrates ultimately available up to 300mm
- Key technology is the survivability of the ROIC structure in the MOVPE growth environment

# MCT Island Growth on ROICS

Optical micrograph showing ROIC pixels



Crystalline Si surface  
growth window

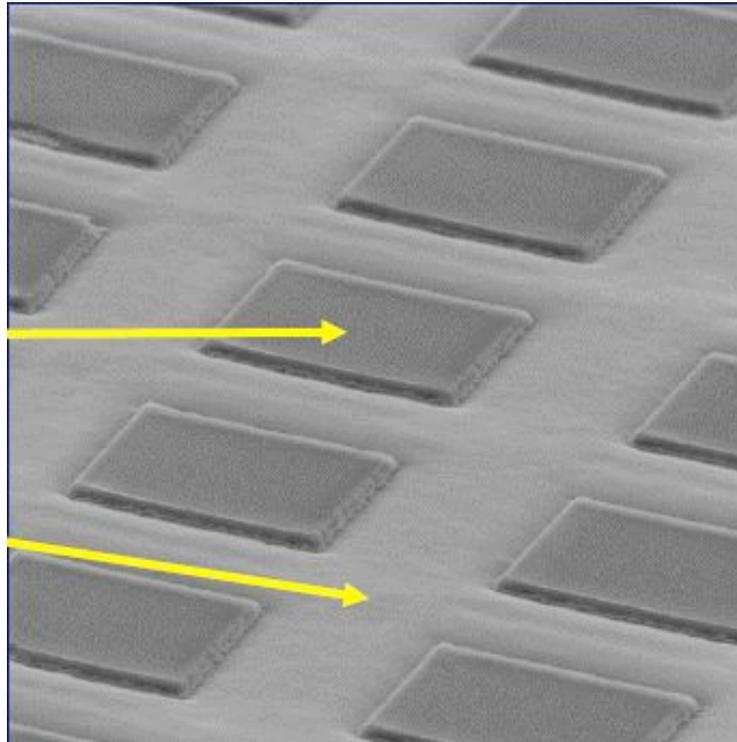
Integrated circuits surrounding  
growth window

# MCT Island Growth on ROICS

- Scanning electron micrograph

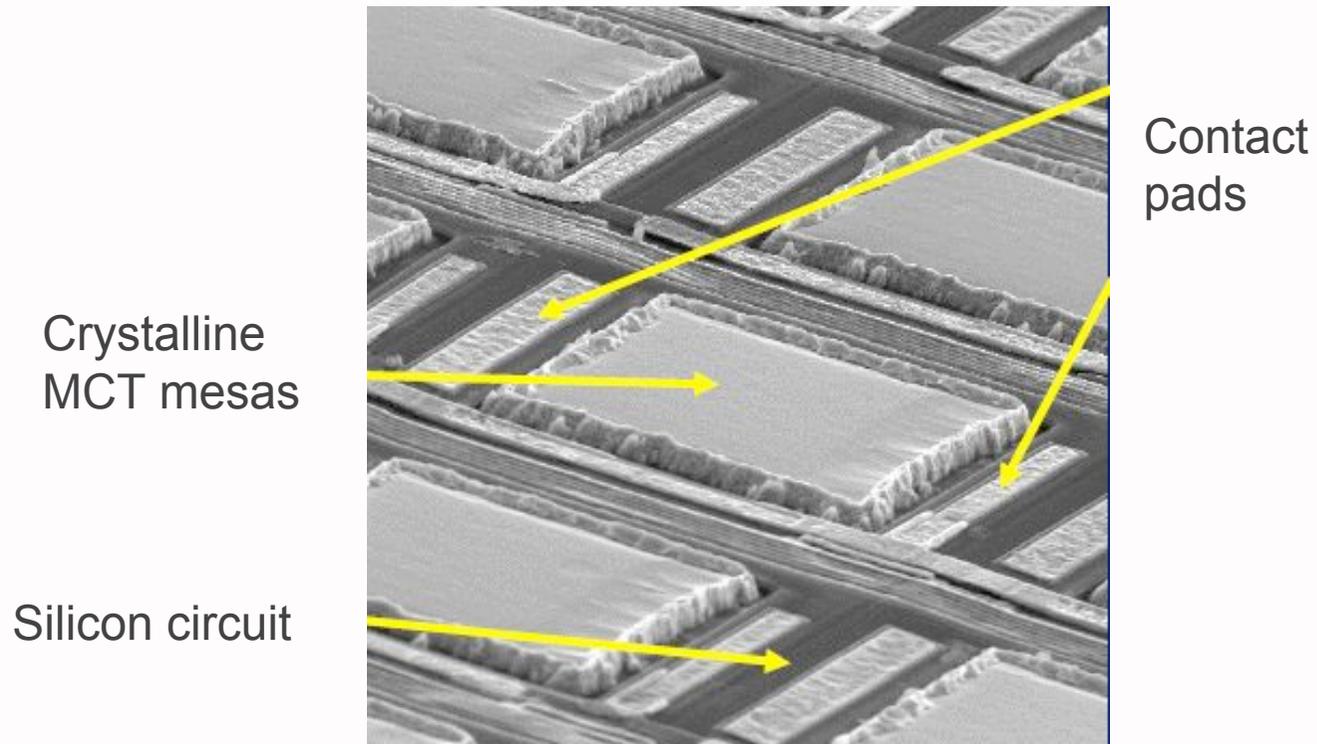
Crystalline  
MCT in  
window areas

Polycrystalline  
MCT



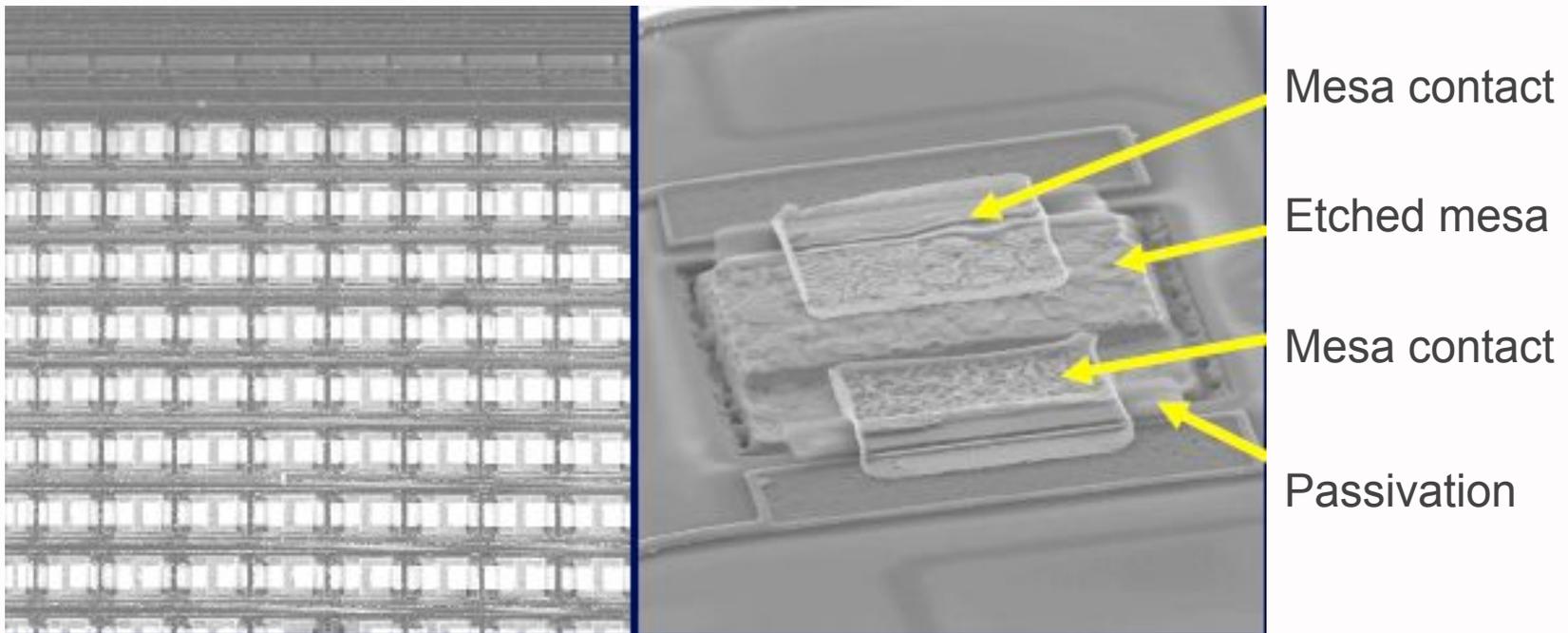
# MCT Island Growth on ROICS

- Scanning electron micrograph of part of processed FPA

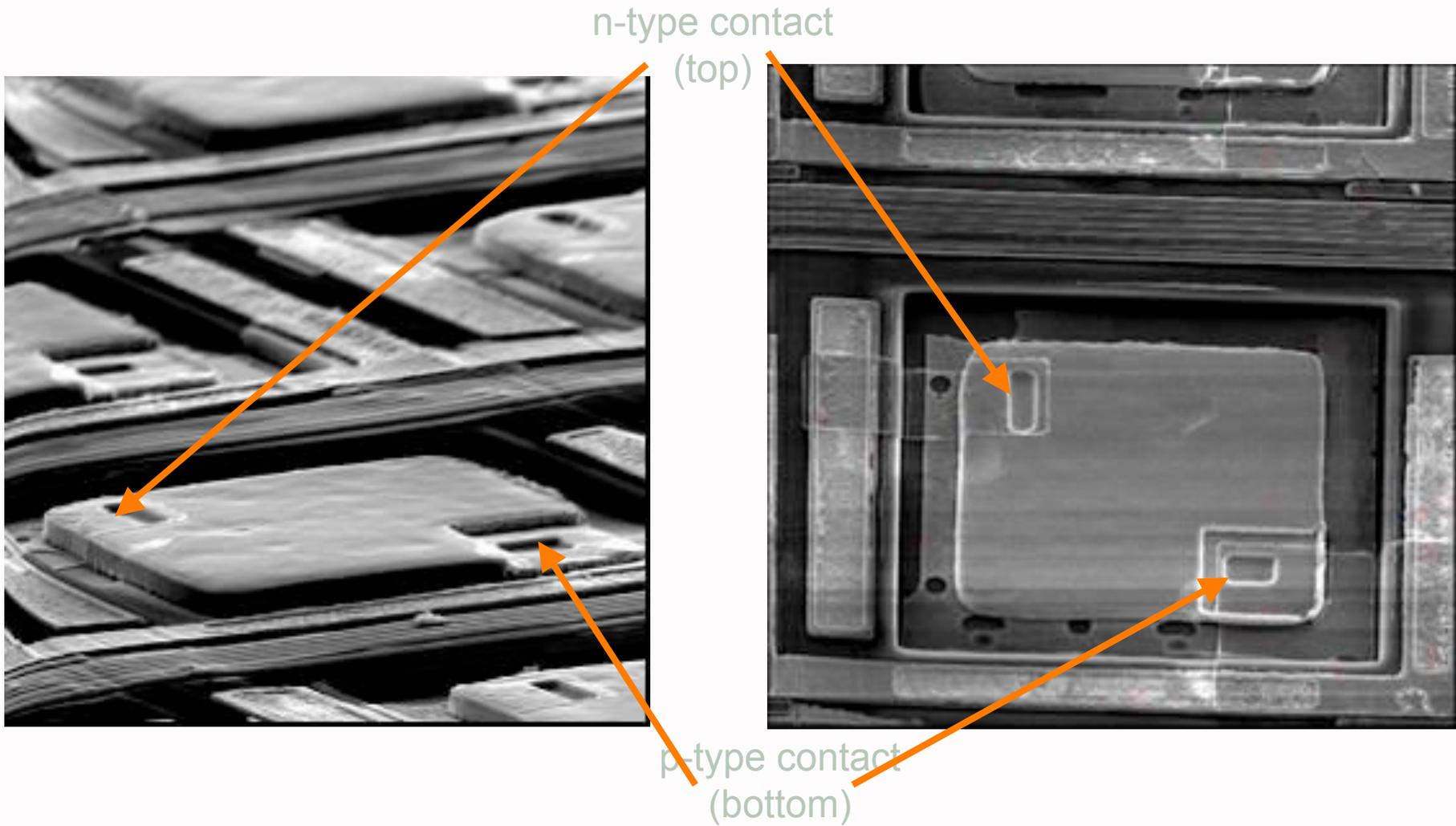


# MCT Island Growth on ROICS

- Example of prototype FPA

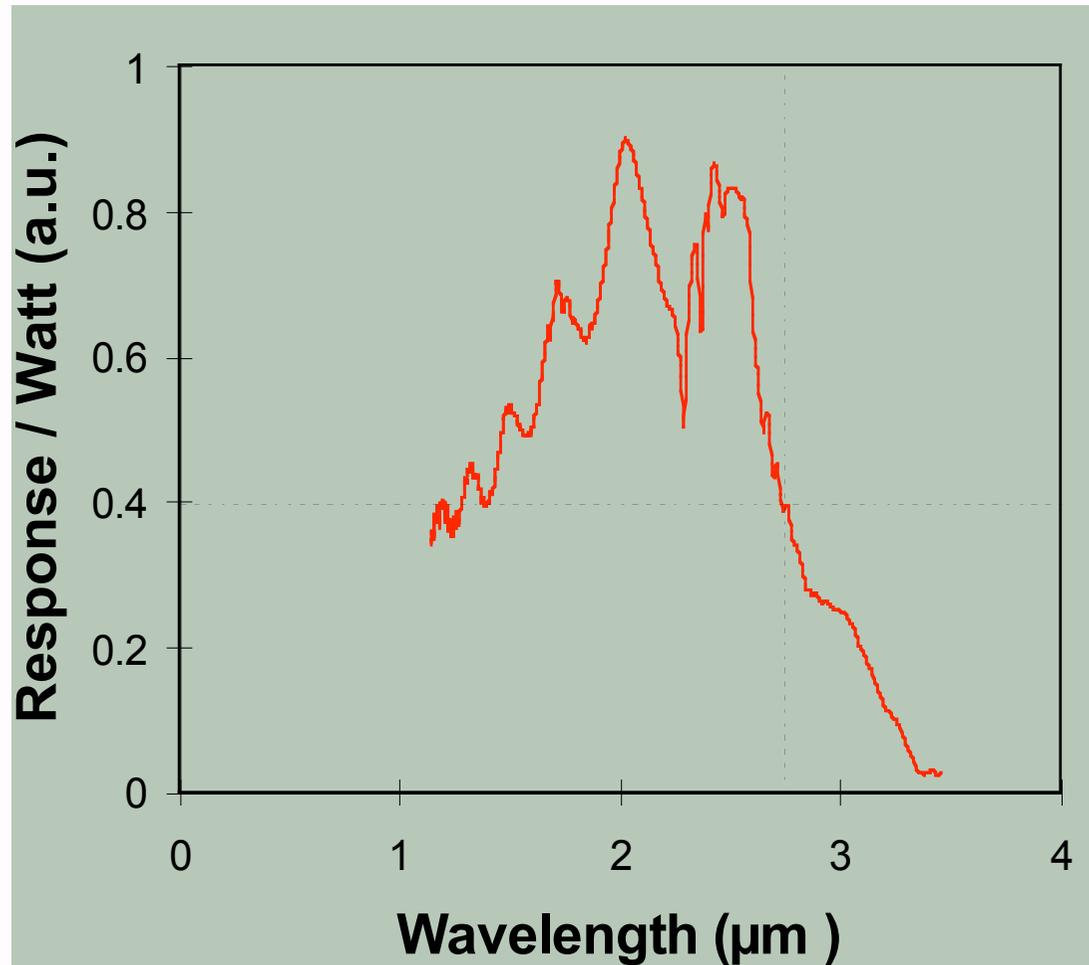


# Test Pixel Growth



75 $\mu$ m pixel grown in 100 $\mu$ m growth window on a test wafer

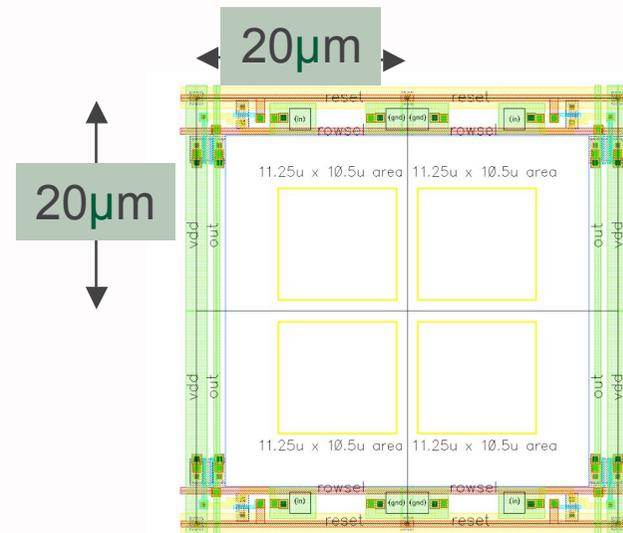
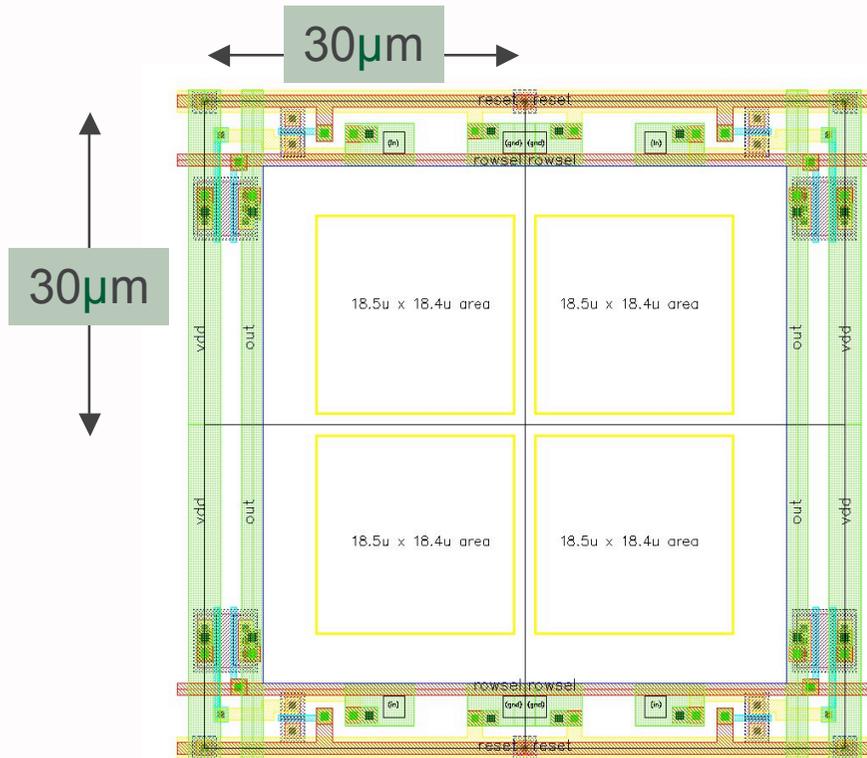
# Test pixel transmission (inferred from back-illuminated test)



# Developments - QinetiQ

- MOVPE growth at high T gives much more control of growth environment than MBE process
- Direct growth onto ROIC mesas - no substrate
- Si substrates ultimately available up to 300mm
- Key technology is the survivability of the ROIC structure in the MOVPE growth environment
- Good SW (1-2.5 $\mu\text{m}$ ) material performance demonstrated
- Larger (36 $\mu\text{m}$ ) pixels optimal for some ELT instruments
  - NB for 150mm wafers and 50 $\mu\text{m}$  pixels = 2048x2048 array (c.f. end of VISTA talk)
- Key specifications appropriate to ELT instruments can be met - Good q.e. & linearity
- Not able to measure dark current at astronomical level
- Key aims are to demonstrate modest array-scale growth of SW device on an appropriate ROIC

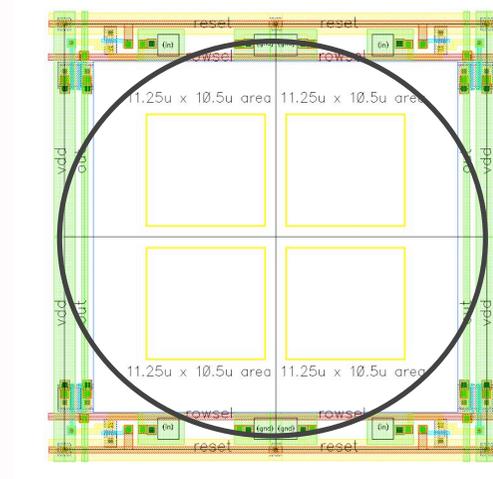
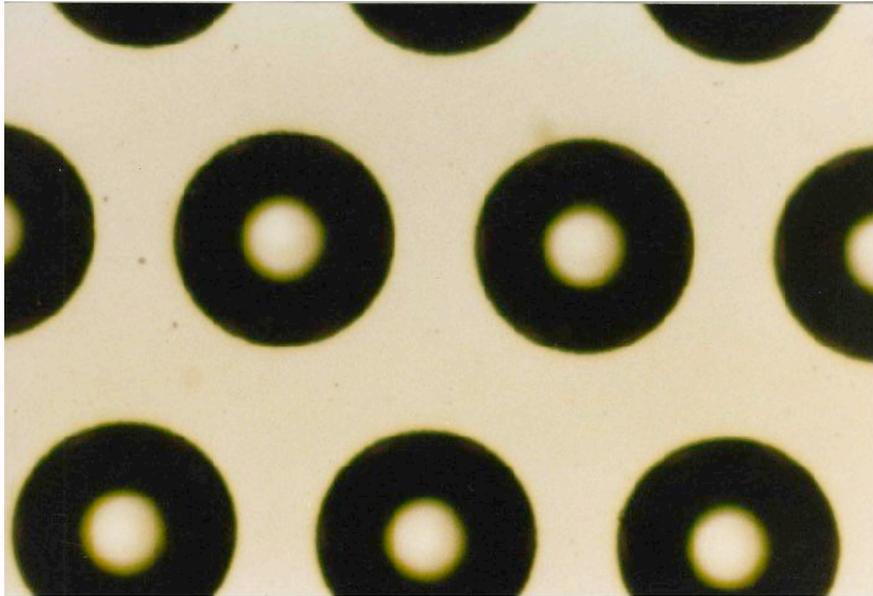
# Small pitch IIDC



- ☞ CX06XI10 0.6µm W process
- ☞ Pixel growth area ~18.5µm x 18.4µm
- ☞ Fill factor ~ 38%

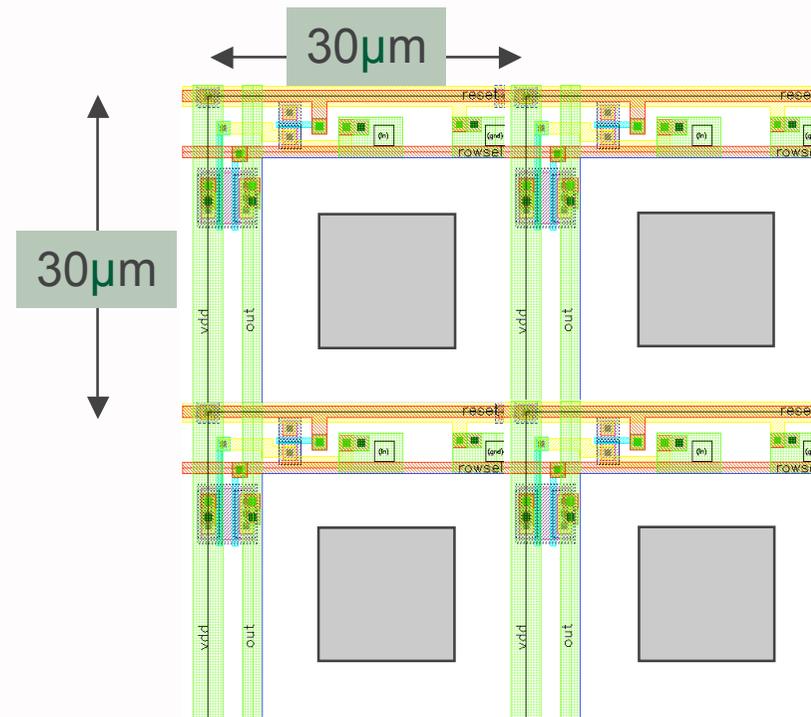
- ☞ XH035 0.35µm Al process
- ☞ Growth area ~12.25µm x 11.5µm
- ☞ Fill factor ~30%

# Optical concentrators – immersion lens



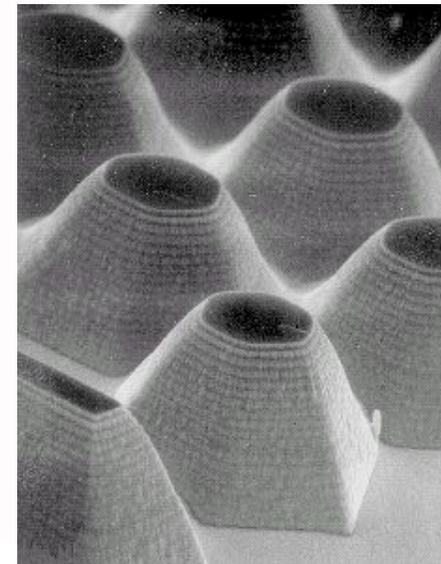
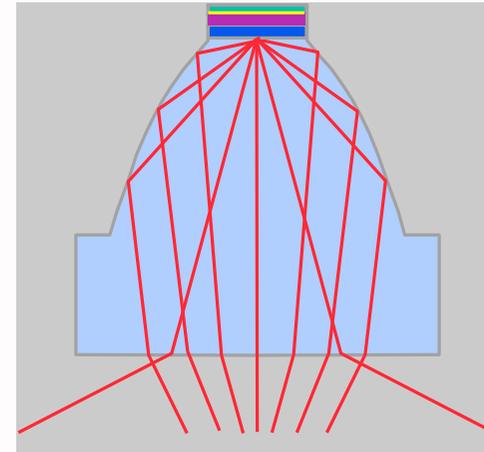
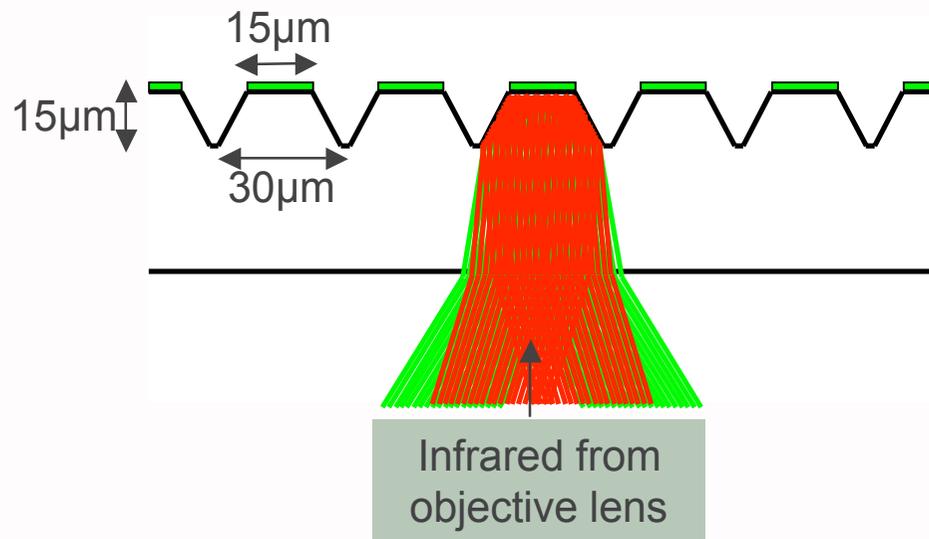
🐉 One immersion lens / 4 pixels

# Constant pitch ROIC



- ☞ CX06XI10 0.6µm W process
- ☞ Pixel growth area  $\sim 13\mu\text{m} \times 13\mu\text{m}$
- ☞ Fill factor  $\sim 19\%$

# Optical concentrators - cones



- Low gain option with area gain of 4
- Substantially reduces dark current/"pixel"

# Prospects

- ☞ ESA TRP announced last week for NIR detector development
  - Terms look favourable to both SELEX and QinetiQ development routes
- ☞ SELEX probably provides the best route to a quick replacement for a H-2RG/H-4RG type device...
- ☞ QinetiQ probably more interesting for wide-field imaging considerations: possibility of migrating to 12" silicon wafer scale devices.

# Longer term...?

NEWS

 LIVE BBC NEWS CHANNEL

News Front Page

[World](#)

[UK](#)

[England](#)

[Northern Ireland](#)

[Scotland](#)

[Wales](#)

[Business](#)

[Politics](#)

[Health](#)

[Education](#)

[Science & Environment](#)

[Technology](#)

[Entertainment](#)

[Also in the news](#)

[Video and Audio](#)

[Have Your Say](#)

[Magazine](#)

[In Pictures](#)

[Country Profiles](#)

Page last updated at 10:47 GMT, Friday, 15 May 2009 11:47 UK

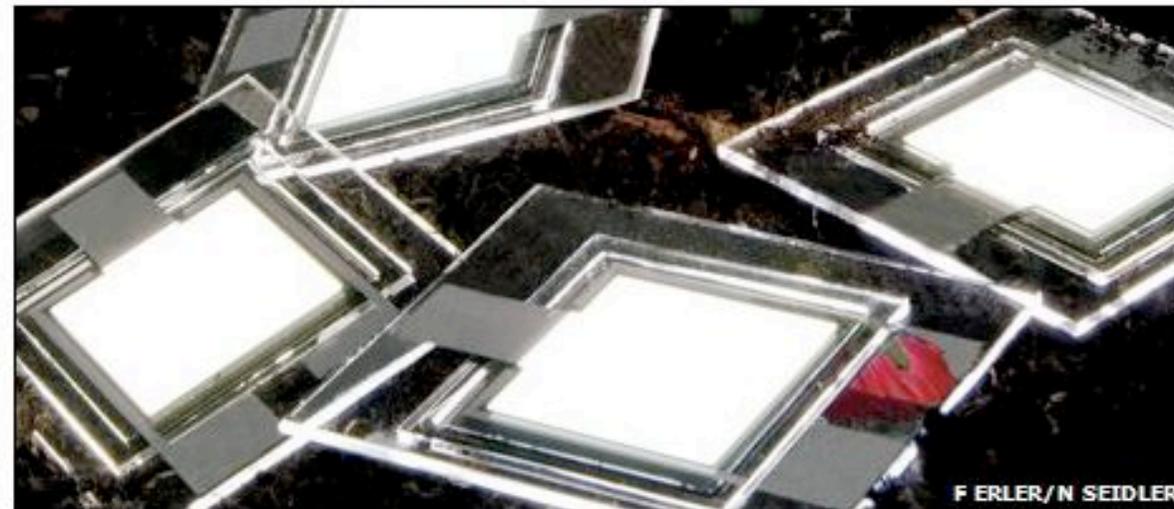
 E-mail this to a friend

 Printable version

## Flat-screen light bulbs switch on

By Jason Palmer

Science and technology reporter, BBC News



The devices are flat - another reason they are desirable as light sources

**Researchers have demonstrated white, organic light-emitting diode (OLED) sources with the same efficiency as fluorescent light bulbs.**



chnology  
ncil